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GEMOLOGICAL  
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

June 20, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

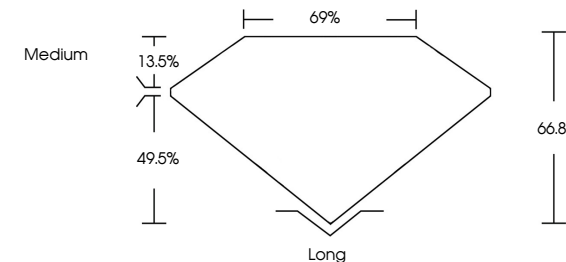
Inscription(s)


Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG717501673

Report verification at [igi.org](http://igi.org)

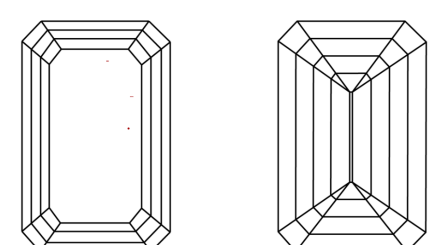
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.  
Green symbols indicate external characteristics.

COLOR


D E F G H I J Faint Very Light Light

CLARITY

IF VS 1-2 VS 1-2 SI 1-2 I 1-3

Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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LABORATORY GROWN DIAMOND

EMERALD CUT

13.85 X 9.52 X 6.36 MM

8.23 CARATS

E


VVS 2

EXCELLENT

EXCELLENT

NONE

IGI LG717501673



IGI

June 20, 2025

IGI Report No LG717501673

EMERALD CUT

13.85 X 9.52 X 6.36 MM

8.23 CARATS

E

VVS 2

66.8%

69%

Medium

Long

EXCELLENT

EXCELLENT



NONE

IGI LG717501673

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